



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

12/a
9-19-96
M. Ross

In re the Application of:

Hidehiko KIRA et al.

Serial Number: 08/393,677

Group Art Unit: 1107

Filed: February 24, 1995

Examiner: David E. GRAYBILL

For: METHOD AND APPARATUS FOR FABRICATING SEMICONDUCTOR DEVICE

RECEIVED
MHS 22 PMD:52
GROUP: 110

AMENDMENT UNDER 37 CFR §1.115

Honorable Commissioner
of Patents and Trademarks
Washington, D.C. 20231

August 16, 1996

Sir:

In response to the Office Action dated February 16, 1996,
please amend the above-identified application as follows:

IN THE SPECIFICATION:

Page 5, line 35, delete "first" (both occurrences), and
insert --second-- in place therefor;

lines 35 and 36, delete "a dispersion of a degree of
collapse of"; and

line 37, delete "absorbed" and insert --deformed
uniformly-- in place therefor.

Page 9, lines 8 and 9, delete "reducing a degree of